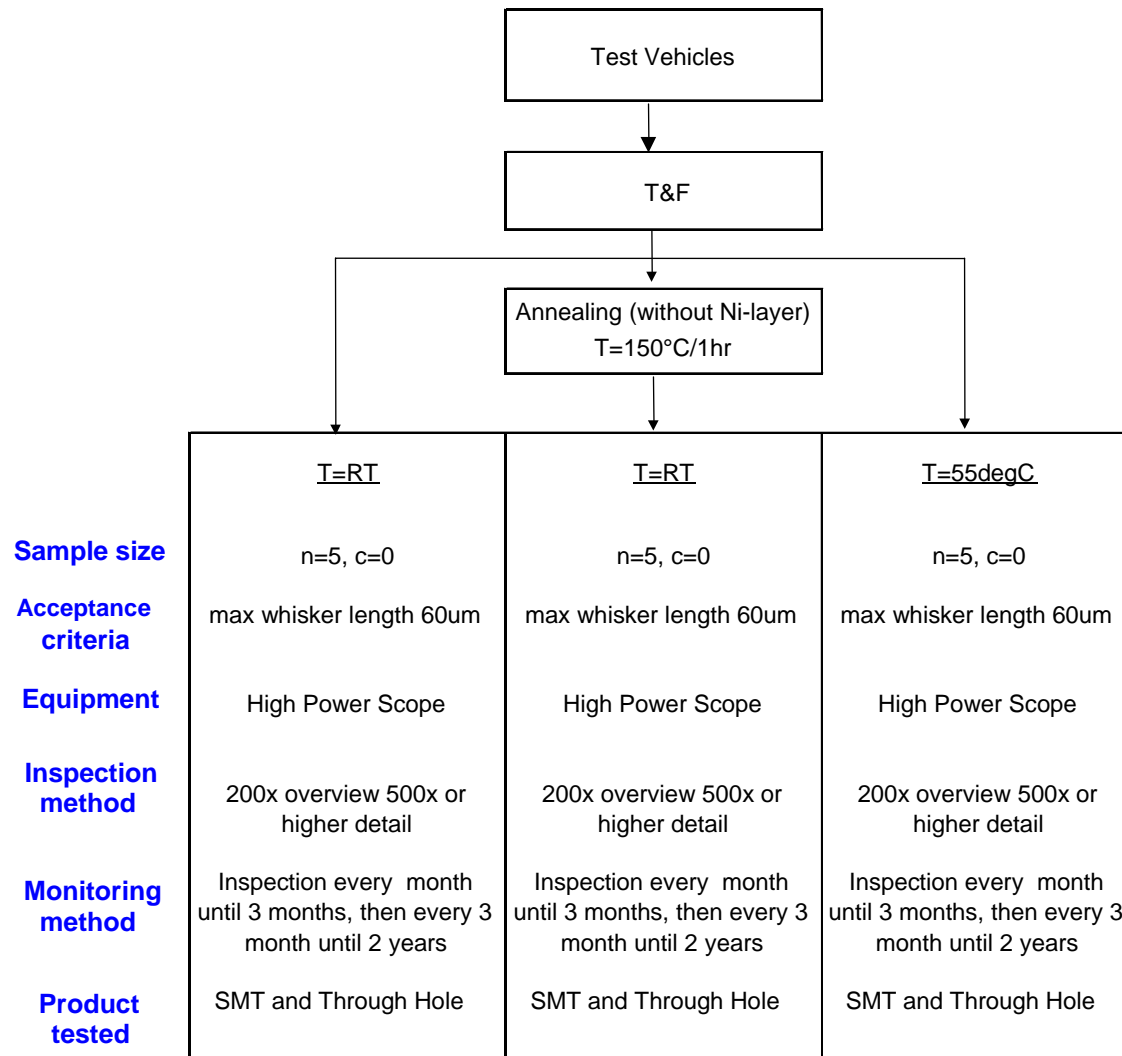


RoHS - Whisker Test

Testflow



Note:
RT=20~30degC and humidity level = 30%rh~60%rh

RoHS - Whisker Test

Classification:
Length

Length 0	non observable whisker growth
Length 1	< 25 μ m
Length 2	< 60 μ m
Length 3	< 100 μ m
Length 4	> 100 μ m

Maximum allowed length for whisker is 60 μ m.

Frequency
(within field of
view by 200x)

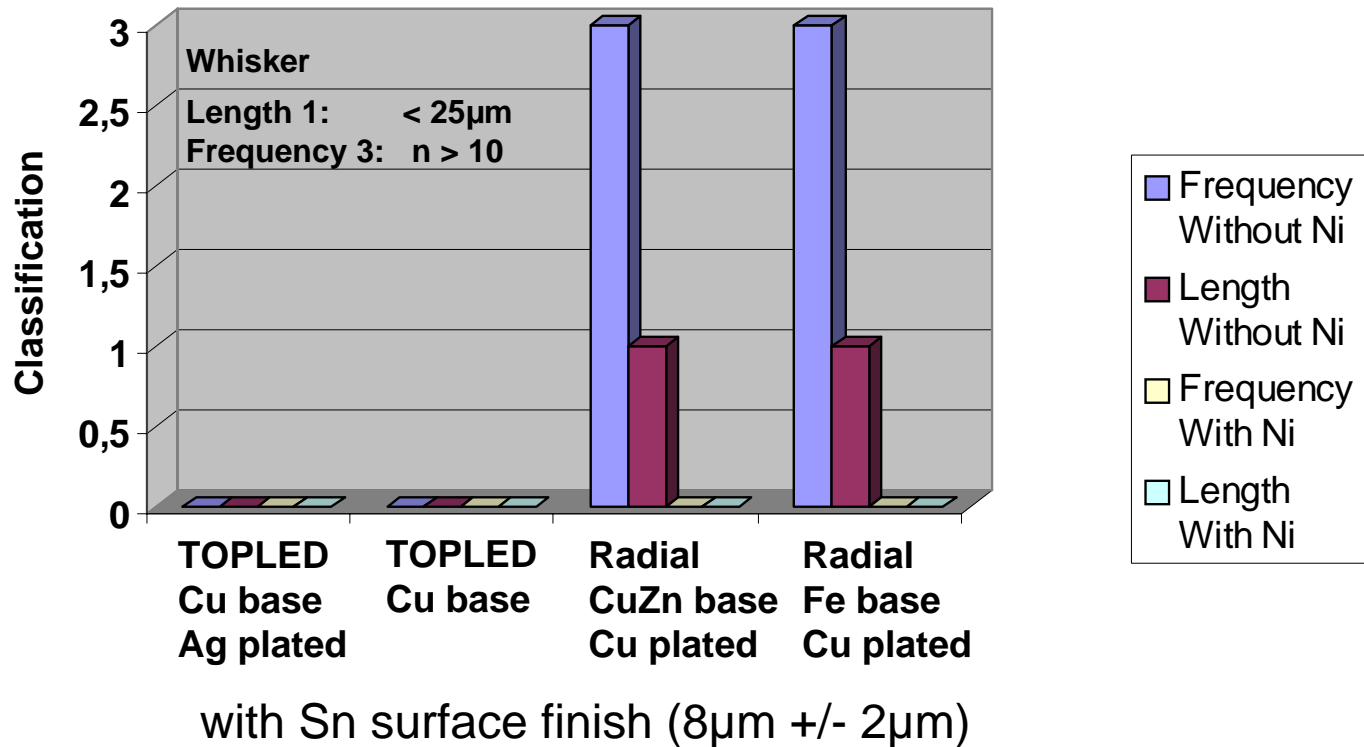
Frequency 1	less or equal 2 whiskers
Frequency 2	3 to 10 whiskers
Frequency 3	more than 10 whiskers

Shape

Shape 1	nodular stubs
Shape 2	filaments (thin needles)

RoHS - Whisker Test

Results after
12 months
(Dec. 03)



With Ni underlayer NO Whisker found

Theory

Influencing factors for whisker - growth

- Diffusion effects between tin layer and base material due to formation of intermetallic layers (IMV)
- Orientation of the tin crystals (texture)
- Grain size of the tin deposit (preferred grain size to prevent whisker-growth is 2 - 5 μm)
- Internal stress of tin deposit (tensile strength prevent whisker-growth)
- Thickness of tin deposit

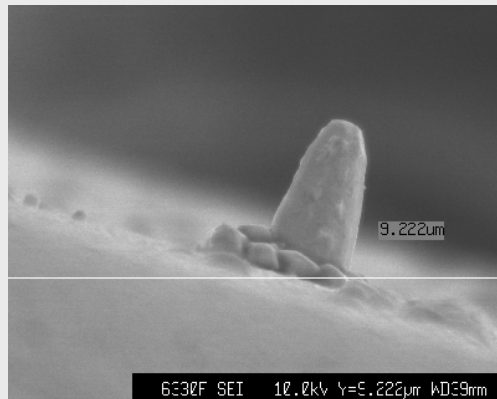
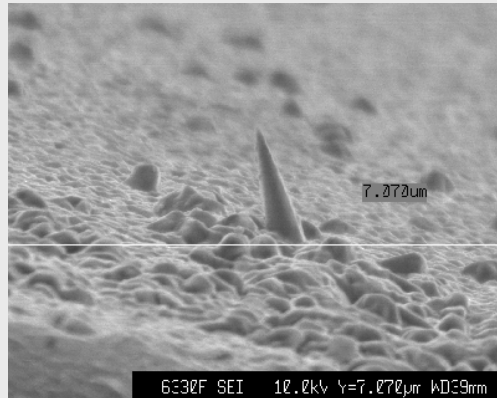
OS Solution

Osram OS actions to prevent whisker - growth

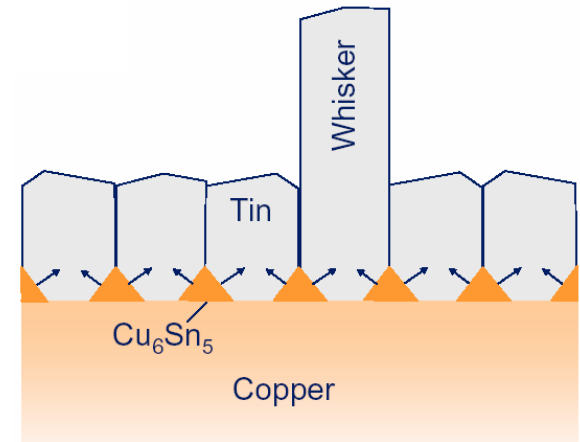
- Plating of nickel underlayer to prevent diffusion (between base material and tin deposit)
- Proven in studies of NASA, ESA, Technic Inc., Shipley, that a nickel layer with thickness $> 0,5\mu\text{m}$ prevent whisker-growth
- Increase of Sn-layer thickness to $8\mu\text{m}$
- Selecting of optimized pure Sn plating chemistry (texture, grain size, internal stress, co-deposition of carbon)

RoHS - Whisker Test

Whisker after
3 months
without Ni -
underlayer



Only very small whisker
< 10 μm length



Main working hypothesis
for whisker growth is the
grain boundary diffusion
between Cu and Sn.